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ingresing Existing Siliest Foundry Facilities in the ESCWA Region

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Stephen L. Bilbert

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The Workshop recommends for the consideration of the respective enterprises the upgrading of existing facilities for manufacturing of bipolar devices at Mansour, Irac, and Sici Bel Abbas. Algeria, with dus attention to increasing their departs for participating in regional operation activities and accepting besigns in bipolar technolog, from several research and development centres in the region. Some considerations in this respect are:

The technology but in place birds 1979 in Algeria and even earlier in Irab is no longer durnent within the broad bipolar becamble). While sufficient for the existing product his vot boss not soldw fabrication of done abvenced bipolar bevides. The serufactioning technology for the existing bipolar becombing has increased since the establishment on these facilities. Were equipped twith higher productivity and presten precision, contributions to lower product post are decision.

process flow. Each continuous appracing of production equipment is necessary to maintain facility viability and should be considered as a normal operational cost at the time of planning of the facility. Currently, such equipments would be better obtained aligners, new diffusion furnace and tobes, more automatic bonders and peckaging equipments. One must consider that the usable life of production equipment for microelectronics lies between three and five years only.

An industrial development group entuid be established for reviewing current operations, and propose shooting, and for processing new surfaction and solutions for increasing new surfaction and solutions for another in operation. But a group would be accordance in operation. But a group would be accordingly and equilate the considerable successes of the Japanese for a apple or promeesing propositivity.

The existing facilities may need to develop greater 13) flexibility in incomponating a none diversified product mix. New designs may be introduced that are compatible with the existing technology and connert designs being produced should be entanced. Some directions could be provided by studying the French e persence with bipoler technology stillization by design groups. One should consider the Sid: Fel Abhas facility to accept designs in bipolar technology from several regional research and cavelorment centres with the specific intertion to verify the design process statility. Such bipolar designs would by their nature be of modest scope and corected at increasing the level of regional composariation and technology a change.